Supporting Information (SI): Electronic and Optical Properties of Two-Dimensional Heterostructures and Heterojunctions between Doped-Graphene and C- and N-containing Materials

A. Bafekry^{a,b*}, D. Gogova^c, Chuong V. Nguyen^d, M. M. Fadlallah^e, Mitra Ghergherehch^f, M. Faraji^g, S. A. H. Feghhi^b, M. Oskoeian^h

 ^aDepartment of Physics, University of Antwerp, Groenenborgerlaan 171, B-2020 Antwerp, Belgium
^bDepartment of Radiation Application, Shahid Beheshti University, Tehran, Iran
^cDepartment of Physics, University of Oslo, P.O. Box 1048, Blindern, Oslo, Norway
^dDepartment of Materials Science and Engineering, Le Quy Don Technical University, Hanoi, Vietnam
^eDepartment of Physics, Faculty of Science, Benha University, 13518 Benha, Egypt
^fCollege of Electronic and Electrical Engineering, Sungkyun Kwan University, Suwon, Korea
^gMicro and Nanotechnology Graduate Program, TOBB University of Economics and Technology, Sogutozu
^bCaddesi No 43 Sogutozu, 06560, Ankara, Turkey
^bDepartment of physics, University of Guilan, 41335-1914 Rasht, Iran



Fig. S1. Optimized structures (top) and band structures (bottom) of (a) graphene, (b) C₃N, (c) BC₃ and (d) h-BN monolayers, (e) density of states (DOS) of these monolayers. The energy is calculated relative to the Fermi energy.



Fig. S2. The dependence of the binding energy on the interlayer distance for Gr/dop@Gr, C₃N/dop@Gr, BC3/dop@Gr and BN/dop@Gr HTSs.



Fig. S3. Ab initio molecular dynamics (AIMD) for $C_3N/dop@Gr$ at 300 K. The top view of optimized structure at 300 K are shown in the inset.

*To whom correspondence should be addressed. bafekry.asad@gmail.com



Fig. S4 The electronic band structure of (a) Gr/dop@Gr, (b) C₃N/dop@Gr, (c) BC3/dop@Gr and (d) BN/dop@Gr HTSs within PBE functional. The zero of energy is at Fermi-level.



Fig. S5. The electronic band structure of (a) Gr-dop@Gr, (b) $C_3N-dop@Gr$, (c) BC3-dop@Gr and (d)BN-dop@Gr HTSs within PBE functional. The zero of energy is at Fermi-level.